



The Fine Line: Autumn 2015 Videos for the eBeam Community

Shot Talk - A Word from Our Sponsor

Aki Fujimura, CEO of D2S, recaps the breaking news and emerging trends that came out of the recently concluded SPIE Photomask BACUS conference, as well as describes what surprised him most about the results of the eBeam Initiative surveys.



Video Archive The Fine Line: Summer 2015 Edition



Shot Talk: Aki Fujimura of D2S

Tech Talk

The Fine Line welcomes Markus Waiblinger of new eBeam Initiative member ZEISS, who explains how low-energy eBeam technology represents a paradigm shift in photomask repair and helps enable Moore's Law.



Tech Talk:
Noriaki Nakayamada,
NuFlare Technology

Perspectives

Brian Grenon of RAVE and Klaus Edinger of ZEISS join Aki Fujimura in breaking down the results of the latest eBeam Initiative surveys during a luminary panel discussion at the eBeam Initiative reception at BACUS.



Perspectives:
Dr. David Lam,
Multibeam Corporation

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The eBeam Initiative provides a forum for educational and promotional activities regarding new semiconductor manufacturing approaches based on electron beam (eBeam) technologies. Its goals are to reduce the barriers to adoption to enable more integrated circuit (IC) design starts and faster time-to-market while increasing the investment in eBeam technologies throughout the semiconductor ecosystem. For more information, please e-mail requests@ebeam.org or visit www.ebeam.org